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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO
10/602,061	06/24/2003	Shibly S. Ahmed	H1105D	1176
7590 06/30/2004		EXAMINER		
Harrity & Snyder, L.L.P.			POMPEY, RON EVERETT	
Suite 300 11240 Waples I	Mill Road		ART UNIT	PAPER NUMBER
Fairfax, VA 22030			2812	
			DATE MAILED: 06/30/2004	

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)					
	10/602,061	AHMED ET AL.					
Office Action Summary	Examiner	Art Unit					
	Ron E Pompey	2812					
The MAILING DATE of this communication appeared for Reply	ears on the cover sheet with the c	orrespondence address					
A SHORTENED STATUTORY PERIOD FOR REPLY THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a reply If NO period for reply is specified above, the maximum statutory period we Failure to reply within the set or extended period for reply will, by statute, Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	6(a). In no event, however, may a reply be time within the statutory minimum of thirty (30) days all apply and will expire SIX (6) MONTHS from the cause the application to become ABANDONED	ely filed will be considered timely. the mailing date of this communication. (35 U.S.C. § 133).					
Status							
1) Responsive to communication(s) filed on	_ .	•					
2a) ☐ This action is FINAL . 2b) ☑ This	This action is FINAL. 2b)⊠ This action is non-final.						
Since this application is in condition for allowance except for formal matters, prosecution as to the merits is							
closed in accordance with the practice under E.	x parte Quayle, 1935 C.D. 11, 45	3 O.G. 213.					
Disposition of Claims							
4)⊠ Claim(s) <u>11-15 and 21-31</u> is/are pending in the application.							
	4a) Of the above claim(s) is/are withdrawn from consideration.						
5) Claim(s) is/are allowed.							
6)⊠ Claim(s) <u>11-15 and 21-31</u> is/are rejected.)⊠ Claim(s) <u>11-15 and 21-31</u> is/are rejected.						
7) Claim(s) is/are objected to.)☐ Claim(s) is/are objected to.						
8) Claim(s) are subject to restriction and/or	election requirement.						
Application Papers							
9)☐ The specification is objected to by the Examiner	·.						
10) The drawing(s) filed on is/are: a) accepted or b) objected to by the Examiner.							
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).							
Replacement drawing sheet(s) including the correcti	on is required if the drawing(s) is obj	ected to. See 37 CFR 1.121(d).					
11) The oath or declaration is objected to by the Ex	aminer. Note the attached Office	Action or form PTO-152.					
Priority under 35 U.S.C. § 119	•						
12) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of: 1. Certified copies of the priority documents 2. Certified copies of the priority documents	have been received. s have been received in Application	on No					
3. Copies of the certified copies of the prior		d in this National Stage					
application from the International Bureau		٠.					
* See the attached detailed Office action for a list of	or the certified copies not receive	u.					
Attachment(s)							
1) Notice of References Cited (PTO-892)	4) Interview Summary (PTO-413) Paper No(s)/Mail Date						
2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08)		atent Application (PTO-152)					
Paper No(s)/Mail Date	6) Other:						

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DETAILED ACTION

Double Patenting

1. The nonstatutory double patenting rejection is based on a judicially created doctrine grounded in public policy (a policy reflected in the statute) so as to prevent the unjustified or improper timewise extension of the "right to exclude" granted by a patent and to prevent possible harassment by multiple assignees. See *In re Goodman*, 11 F.3d 1046, 29 USPQ2d 2010 (Fed. Cir. 1993); *In re Longi*, 759 F.2d 887, 225 USPQ 645 (Fed. Cir. 1985); *In re Van Ornum*, 686 F.2d 937, 214 USPQ 761 (CCPA 1982); *In re Vogel*, 422 F.2d 438, 164 USPQ 619 (CCPA 1970);and, *In re Thorington*, 418 F.2d 528, 163 USPQ 644 (CCPA 1969).

A timely filed terminal disclaimer in compliance with 37 CFR 1.321(c) may be used to overcome an actual or provisional rejection based on a nonstatutory double patenting ground provided the conflicting application or patent is shown to be commonly owned with this application. See 37 CFR 1.130(b).

Effective January 1, 1994, a registered attorney or agent of record may sign a terminal disclaimer. A terminal disclaimer signed by the assignee must fully comply with 37 CFR 3.73(b).

2. Claims 11 and 21 are provisionally rejected under the judicially created doctrine of obviousness-type double patenting as being unpatentable over claim 9 of copending Application No. 10/770,011. Although the conflicting claims are not identical, they are not patentably distinct from each other because the claim language in claim 9 of copending application 10/770,011 discloses the same method of making a device as claims 11 and 21 of the present application just in different order.

This is a <u>provisional</u> obviousness-type double patenting rejection because the conflicting claims have not in fact been patented.

Claim Rejections - 35 USC § 102

3. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

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(e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.

- 4. Claims 11, 13-15 and 21, 23-26 and 28-29 rejected under 35 U.S.C. 102(e) as being anticipated by Mathew et al. (US-PGPub. 2003/0,151,077) or Yu (US 6,458,662).
- 5. Mathew discloses the limitations of:

forming an insulating layer on a substrate;

forming a fin structure (24, fig. 2) on the insulating layer, the fin structure including a first side surface, a second side surface, and a top surface;

forming source and drain regions at ends of the fin structure (52 and 54, fig. 9);

depositing a gate material (28, fig. 3) over the fin structure, the gate material surrounding the top surface and the first and second side surfaces;

etching the gate material to form a first gate electrode and a second gate electrode (46 and 48, fig. 9) on opposite sides of the fin; and

planarizing the deposited gate material proximate to the fin (50, fig. 8) (column 2, paragraph [0016] – column 5, paragraph [0024]).

6. Yu discloses the limitations of:

forming an insulating layer on a substrate;

forming a fin structure (35, fig. 3) on the insulating layer, the fin structure including a first side surface, a second side surface, and a top surface;

forming source and drain regions at ends of the fin structure (50, fig. 6);

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depositing a gate material (40, fig. 4) over the fin structure, the gate material surrounding the top surface and the first and second side surfaces;

etching the gate material to form a first gate electrode and a second gate electrode (45, fig. 6) on opposite sides of the fin; and planarizing the deposited gate material proximate to the fin (41, fig. 5) (column 3, line 24 – column 4, line 15).

Claim Rejections - 35 USC § 103

- 7. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 8. Claims 12, 22, 27 and 30-31 are rejected under 35 U.S.C. 103(a) as being obvious over Mathew et al. (US-PGPub. 2003/0,151,077) and Yu (US 6,458,662) in further view of Gambino et al. (US 6,689,650).

The applied reference, Yu, has a common inventor with the instant application. Based upon the earlier effective U.S. filing date of the reference, it constitutes prior art only under 35 U.S.C. 102(e). This rejection under 35 U.S.C. 103(a) might be overcome by: (1) a showing under 37 CFR 1.132 that any invention disclosed but not claimed in the reference was derived from the inventor of this application and is thus not an invention "by another"; (2) a showing of a date of invention for the claimed subject matter of the application which corresponds to subject matter disclosed but not claimed in the reference, prior to the effective U.S. filing date of the reference under 37 CFR

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However,

1.131; or (3) an oath or declaration under 37 CFR 1.130 stating that the application and reference are currently owned by the same party and that the inventor named in the application is the prior inventor under 35 U.S.C. 104, together with a terminal disclaimer in accordance with 37 CFR 1.321(c). For applications filed on or after November 29, 1999, this rejection might also be overcome by showing that the subject matter of the reference and the claimed invention were, at the time the invention was made, owned by the same person or subject to an obligation of assignment to the same person. See MPEP § 706.02(I)(1) and § 706.02(I)(2).

Mathew and Yu do not disclose the claimed limitation(s) of:

annealing the semiconductor device to activate the source and drain regions; and the thickness of the gate dielectric layer or gate material.

a. Gambino discloses the above claimed limitations regarding: activating the source/drain in column(s) 6, line(s) 63 - column(s) 7, line(s) 4.

Therefore, it would have been obvious to one of ordinary skill in the art at the time of the invention to combine Gambino with Matthew or Yu, because the annealing activates the source/drain regions of the device. Also, It would have been obvious to one of ordinary skill in the art at the time of the invention to form the gate dielectric or gate material to the thickness range claimed, since it has been held that where the general conditions of a claim are disclosed in prior art, discovering the optimum or working ranges involves only routine skill in the art. In re Aller, 105 USPQ 233.

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Claim Objections

2. Claim 27 is objected to because of the following informalities: claim 27 is a duplicate of claim 22. Appropriate correction is required.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Ron E Pompey whose telephone number is (571) 272-1680. The examiner can normally be reached on flex schedule.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, John Niebling can be reached on (571) 272-1679. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Ron Pompey

AU: 2812 June 24, 2004 John F. Niebling
Supervisory Patent Examiner
Technology Center 2800